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## **Supplementary Materials**

## Probing into the mechanisms of disinfection byproduct formation from natural organic matter and model compounds after UV/chlorine treatment

Ding Wang<sup>a,b,1</sup>, Zhechao Hua<sup>a,1</sup>, Yonglin Cui<sup>a</sup>, Zijun Dong<sup>c</sup>, Chen Li<sup>d</sup>, Jingyun Fang<sup>a,\*</sup>

<sup>a</sup> Guangdong Provincial Key Laboratory of Environmental Pollution Control and Remediation
Technology, School of Environmental Science and Engineering, Sun Yat-sen University, Guangzhou,
510275, China

<sup>b</sup> General Institute of Water Resources and Hydropower Planning and Design, Beijing 100120, China

<sup>c</sup> College of Civil and Transportation Engineering, the Underground Polis Academy, Shenzhen University, Shenzhen 518048, China

<sup>d</sup> Jiangsu Academy of Environmental Industry and Technology Corp., Nanjing 210019, China

\* Corresponding author. E-mail: <u>fangjy3@mail.sysu.edu.cn</u>

<sup>1</sup> Shared first authorship.

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	$k_{\text{chlorine}} (\mathrm{M}^{-1} \mathrm{s}^{-1})$	<i>k</i> <sub>HO</sub> • (M <sup>-1</sup> s <sup>-1</sup> )	$k_{\text{Cl}}$ (M <sup>-1</sup> s <sup>-1</sup> )	$k_{\text{Cl}_2} \cdot (\text{M}^{-1} \text{ s}^{-1})$	$k_{\text{CIO}}$ (M <sup>-1</sup> s <sup>-1</sup> )
NOM	2.4 [1]	$3 \times 10^{8}  ^{[2]}$	$1.6 \times 10^{8}$ [2]	$1.7  imes 10^{7}$ [2]	$5.4 \times 10^{8}$ <sup>[3]</sup>
Phenol	18 [4]	$6.6  imes 10^{9}  {}^{[5]}$	$1.1  imes 10^{10}$ [5]	$3.2  imes 10^{8}  {}^{[5]}$	$3.4\times10^{6\text{b}}$
Resorcinol	$4  imes 10^{3}$ [4]	$1.2  imes 10^{10}$ [6]	$1.4  imes 10^{10}\text{a}$	$8.6 imes10^{9a}$	$2.2 \times 10^{6 \text{ b}}$
Benzoic acid	Negligible <sup>[4]</sup>	5.9 × 10 <sup>9 [7]</sup>	$1.8  imes 10^{10}$ [7]	$2 \times 10^{6}$ [7]	$< 1 \times 10^{6}$ [7]
Methylamine	$3.2 \times 10^{4}$ <sup>[4]</sup>	N.D.	N.D.	N.D.	N.D.
Dimethylamine	$8.9  imes 10^{3}$ <sup>[4]</sup>	N.D.	N.D.	N.D.	N.D.
Tyrosine	$\sim 1 \times 10^{4}  {}^{[4]}$	$1.3  imes 10^{10}$ [6]	$1.2  imes 10^{10}\text{a}$	$4.6  imes 10^{8 \text{ a}}$	N.D.
Asparagine	$\sim 1 \times 10^{4}  {}^{[4]}$	$4.9  imes 10^{7}$ [6]	$7.2  imes 10^{8  a}$	Negligible <sup>a</sup>	N.D.

Table S1. Rate constants of NOM and model compounds with free chlorine and radicals at pH 7.0.

N.D. = Not determined.

<sup>a</sup> Determined in this study.

<sup>b</sup> Assumed in this study.

	$UV_{254}(cm^{-1})$	DOC (mg/L)	SUVA (L/mg/m)
Untreated NOM	0.1112	3	3.7
Chlorination	0.0892	2.7	3.3
UV/chlorine	0.0456	2.4	1.9
UV	0.1063	2.9	3.7

**Table S2.** Alteration of UV absorbance at 254 nm (UV254), DOC concentration and specific UVabsorbance (SUVA) of NOM after chlorination, UV/chlorine and UV treatments.



**Figure S1.** Chlorine residuals after 10 min UV, chlorination and UV/chlorine treatment, and 24 h post chlorination. Conditions: [NOM] = 3 mg/L, [model compounds] = 50  $\mu$ M, [chlorine] = 15 mg/L for NOM, 300  $\mu$ M for benzoate, methylamine, and dimethylamine, 500  $\mu$ M for phenol, resorcinol, and asparagine, and 750  $\mu$ M for tyrosine, pH = 7.0.



Figure S2. The contributions of reactive species to NOM transformation in the UV/chlorine process. Conditions: [NOM] = 3 mg/L, [chlorine] = 15 mg/L, pH = 7.0.



**Figure S3.** The degradation of phenol and the formation of chlorophenols in chlorination (a) and UV/chlorine process (b). Conditions: [phenol] = 50  $\mu$ M, [chlorine] = 500  $\mu$ M, pH = 7.0.



**Figure S4.** The formation of methylamine from dimethylamine during UV/chlorine treatment. Conditions:  $[dimethylamine]_0 = 50 \ \mu\text{M}$ ,  $[chlorine] = 300 \ \mu\text{M}$ , pH = 7.0.

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